

ESI:

Hierarchical Cu₂S@NiCo-LDH double-shelled nanotube arrays with enhanced electrochemical performance for hybrid supercapacitors

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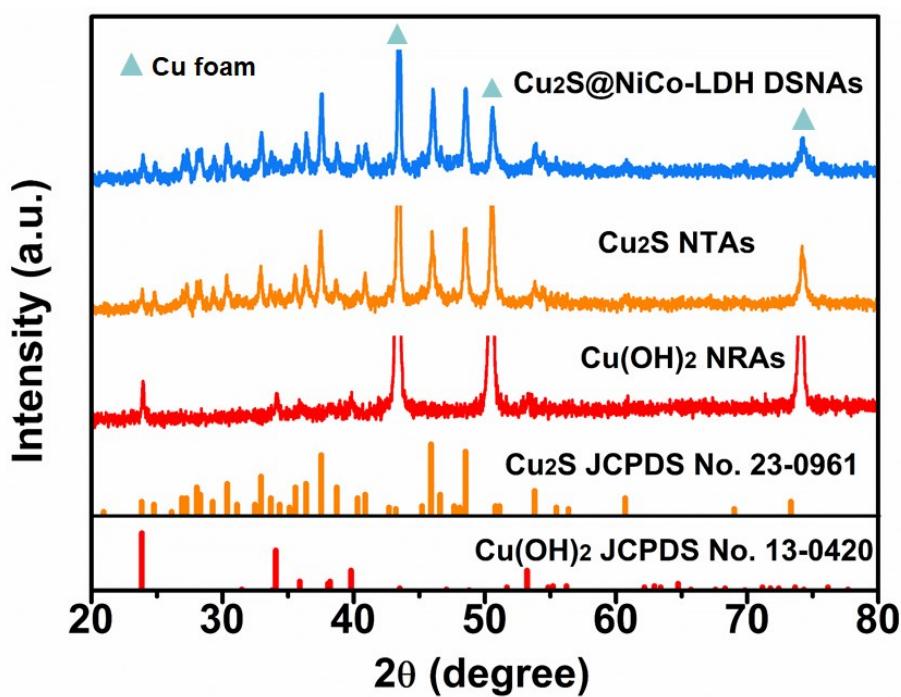


Fig. S1 XRD patterns of the as-prepared Cu(OH)₂ NRAs, Cu₂S NTAs and Cu₂S@NiCo-LDH DSNAs.

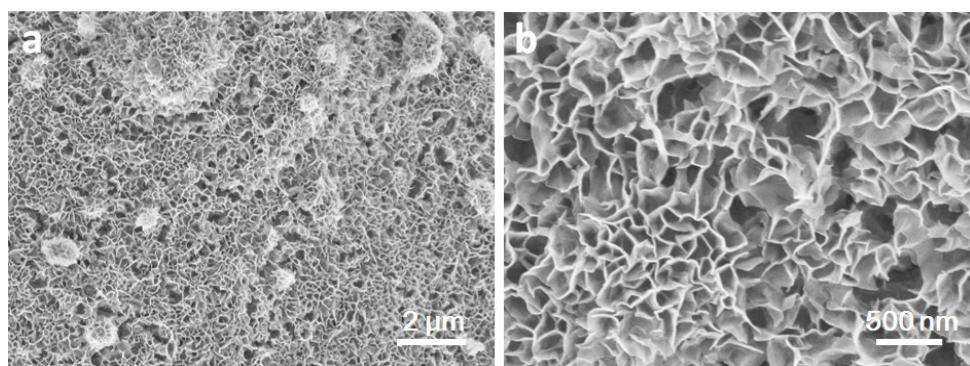


Fig. S2 FE-SEM images of the as-prepared NiCo-LDH NSs.

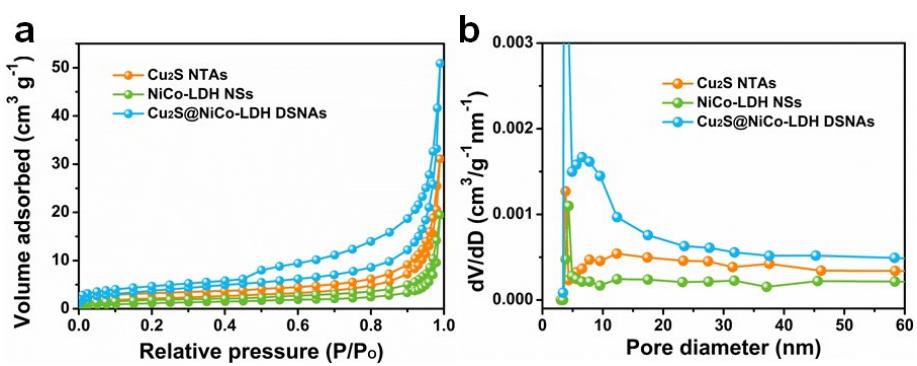


Fig. S3 (a) N₂ adsorption-desorption isotherms, and (b) pore size distribution curves of the Cu₂S@NiCo-LDH DSNAs, NiCo-LDH NSs and Cu₂S NTAs.

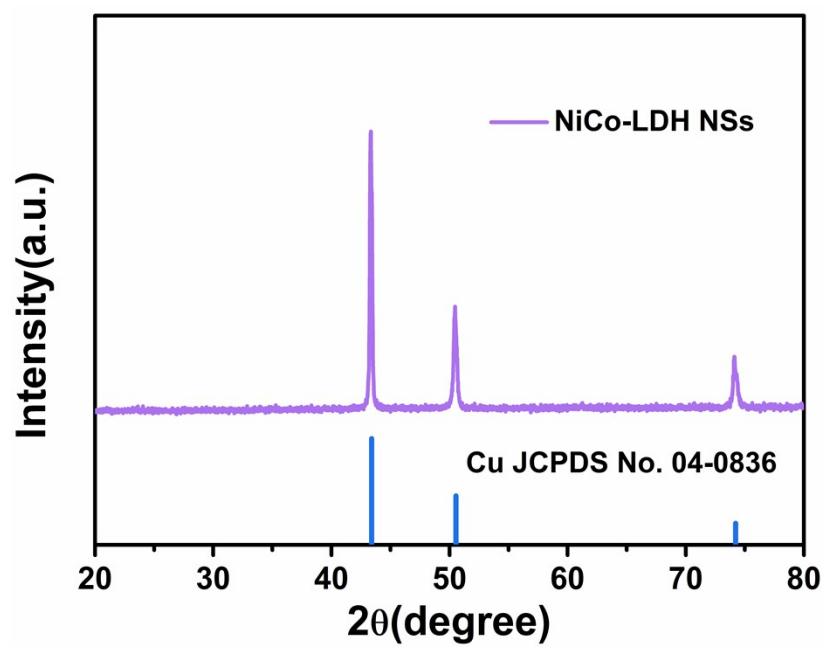


Fig. S4 XRD pattern of the as-prepared NiCo-LDH NSSs.

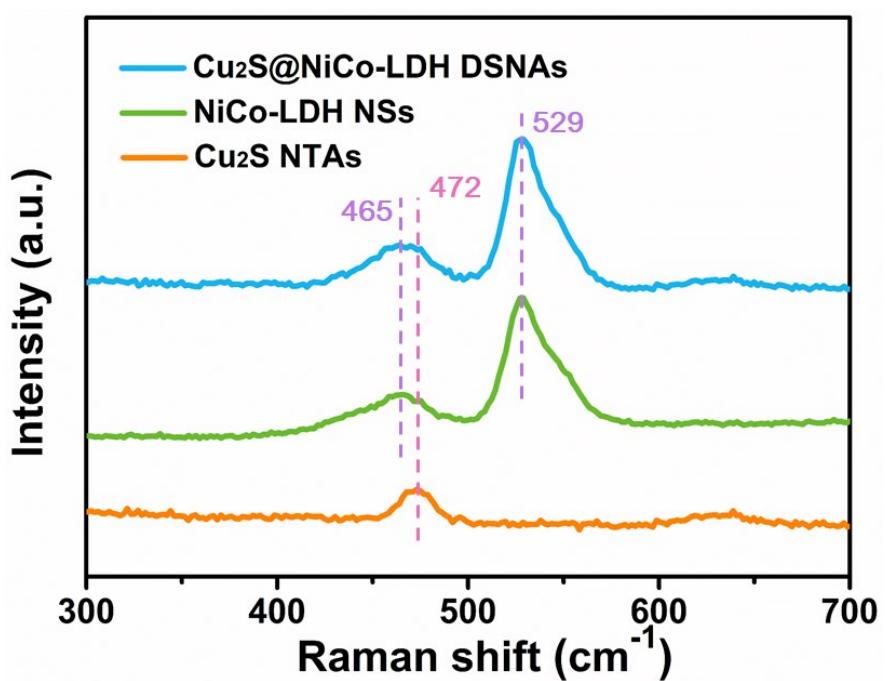


Fig. S5 Raman spectra of the Cu₂S@NiCo-LDH DSNA, NiCo-LDH NSs and Cu₂S NTAs.

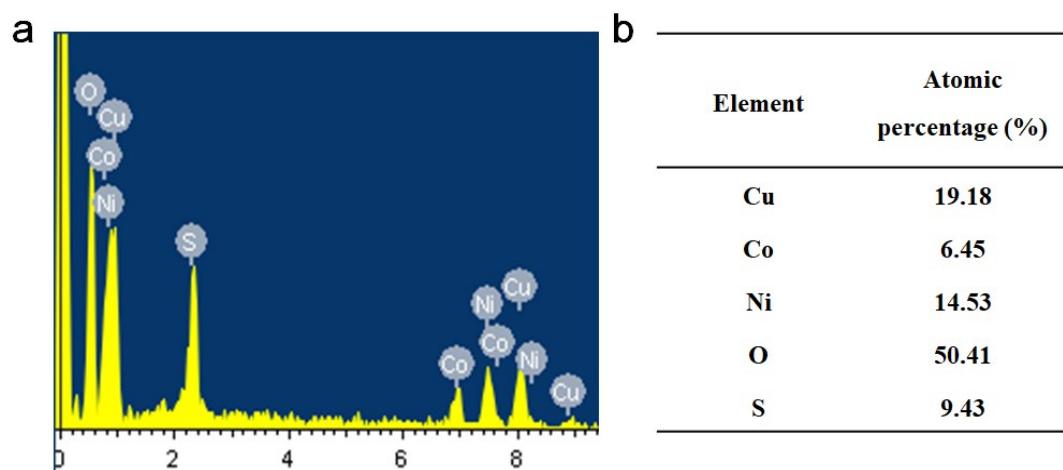


Fig. S6 (a) EDX spectrum and (b) atomic percentage of the as-prepared Cu₂S@NiCo-LDH DSNAs sample.

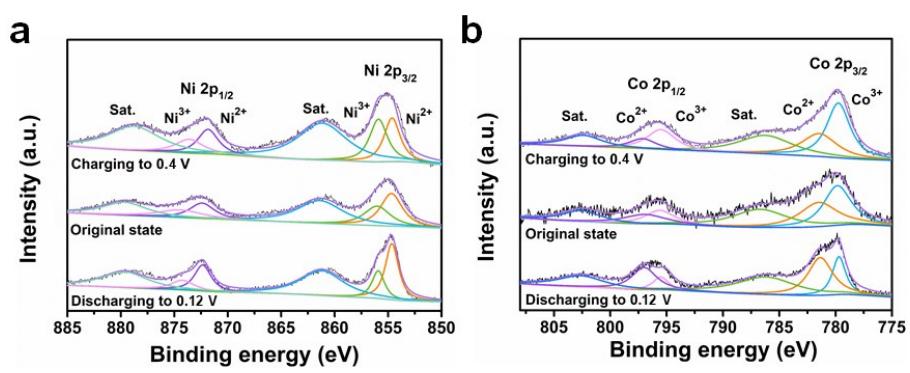


Fig. S7 The high-resolution XPS of (a) Ni 2p and (b) Co 2p of Cu₂S@NiCo-LDH DSNAs at the original state and with charge/discharge states.

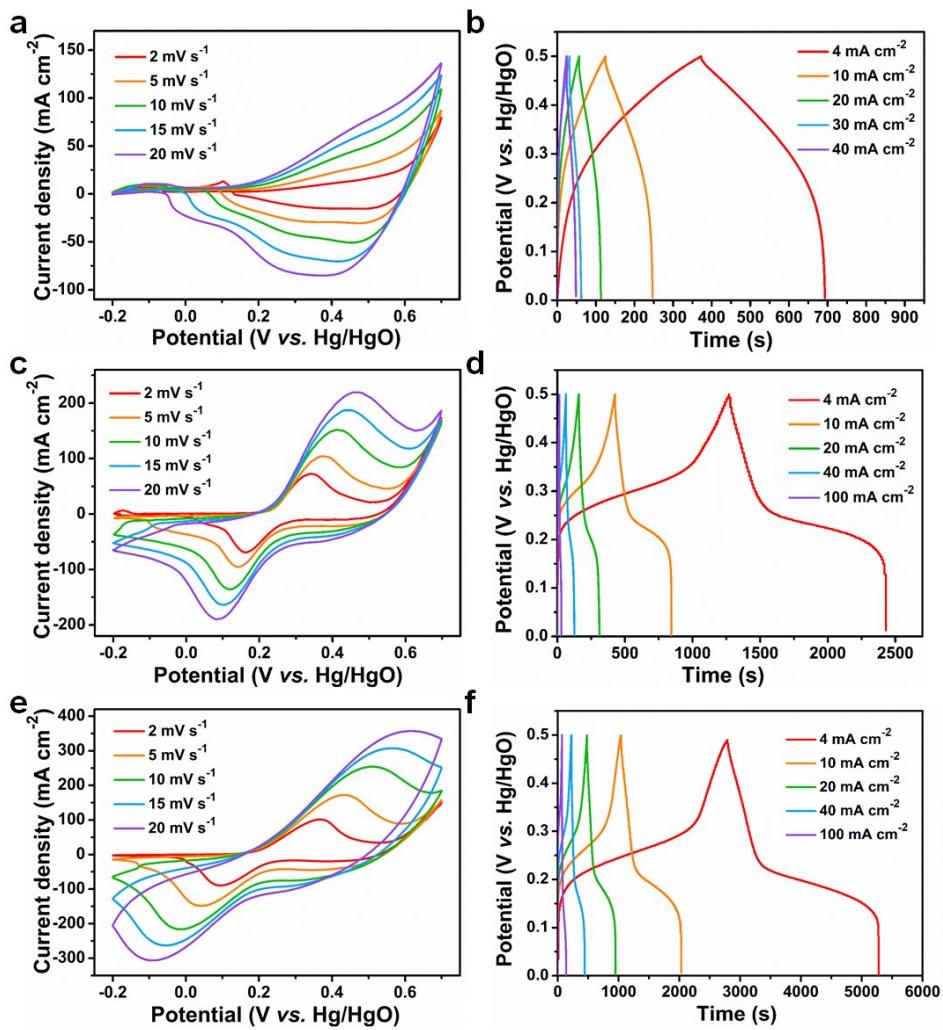


Fig. S8 CV curves of the as-prepared (a) Cu₂S NTAs, (c) NiCo-LDH NSs, (e) Cu₂S@NiCo-LDH DSNAs at various scan rates, GCD curves of (b) Cu₂S NTAs, (d) NiCo-LDH NSs, (f) Cu₂S@NiCo-LDH DSNAs at various current densities.

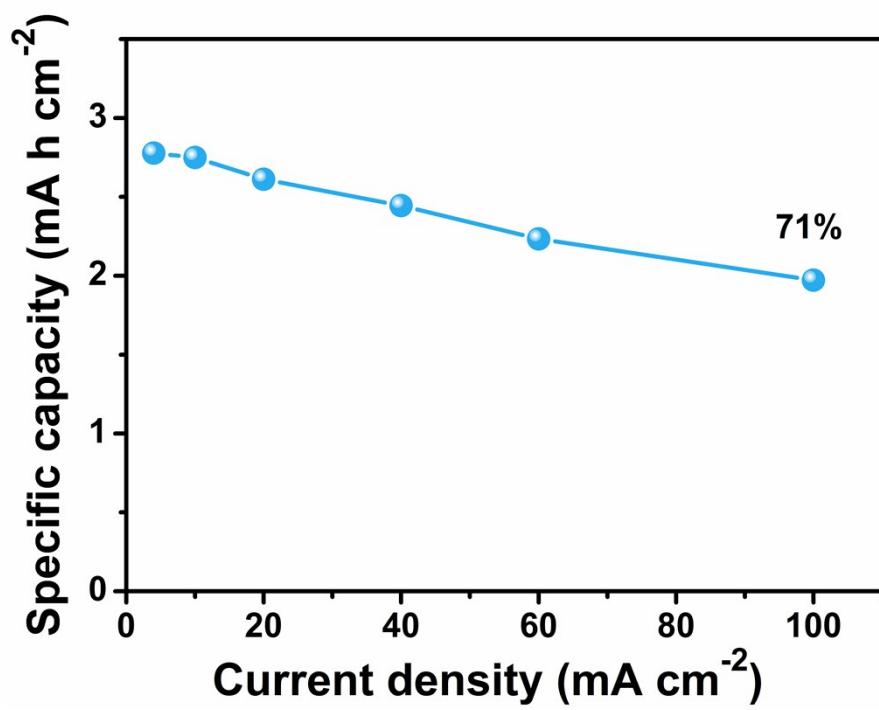


Fig. S9 The specific capacities of the $\text{Cu}_2\text{S}@\text{NiCo-LDH}$ DSNAs at different current densities.

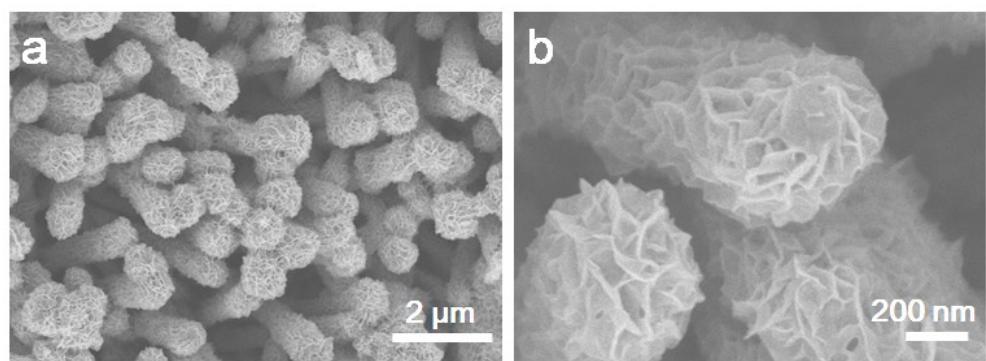


Fig. S10 (a, b) FE-SEM images of the $\text{Cu}_2\text{S}@\text{NiCo-LDH}$ DSNAs after cyclic stability test.

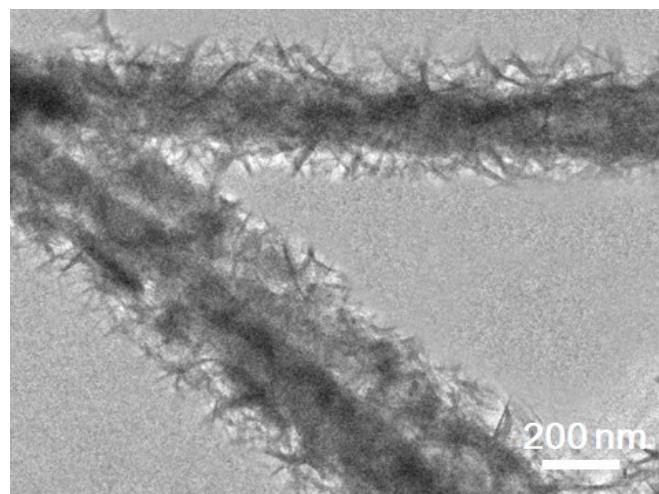


Fig. S11 TEM image of the Cu₂S@NiCo-LDH DSNAs after cyclic stability test.

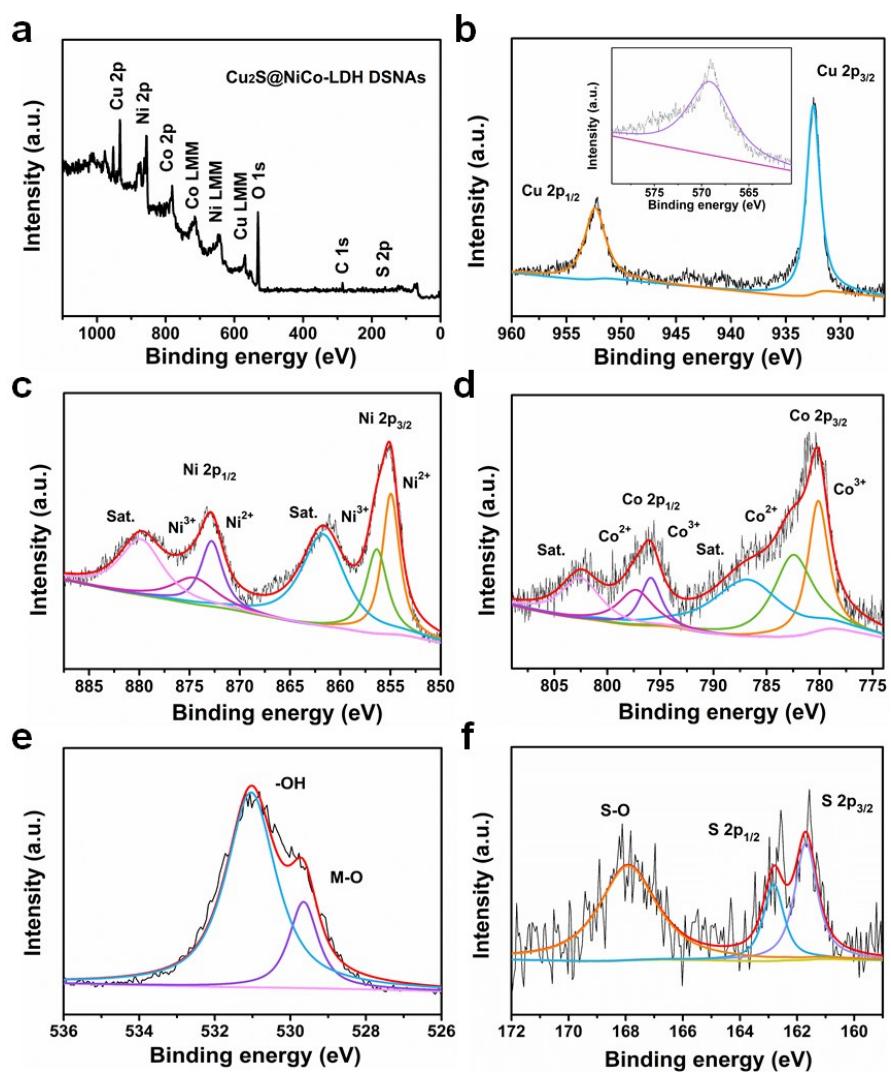


Fig. S12 XPS spectra of the Cu₂S@NiCo-LDH DSNAs after cyclic stability test. (a) Survey spectra and the high-resolution XPS of (b) Cu 2p (inset shows the Auger Cu LMM lines), (c) Ni 2p, (d) Co2p, (e) O 1s and (f) S 2p.

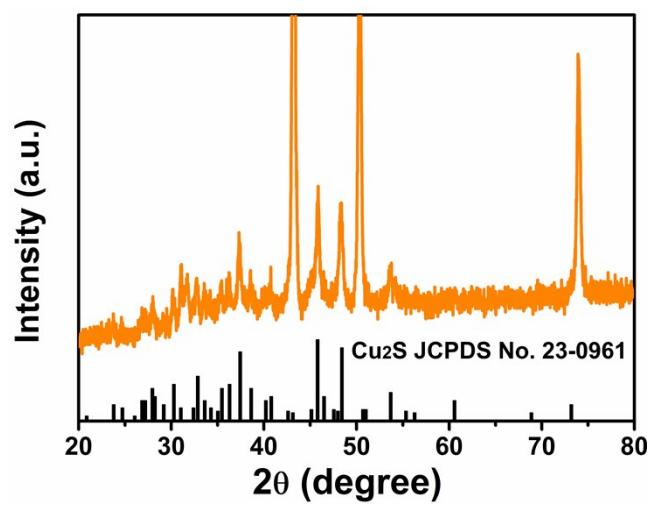


Fig. S13 XRD pattern of the Cu₂S@NiCo-LDH DSNAs after cyclic stability test.

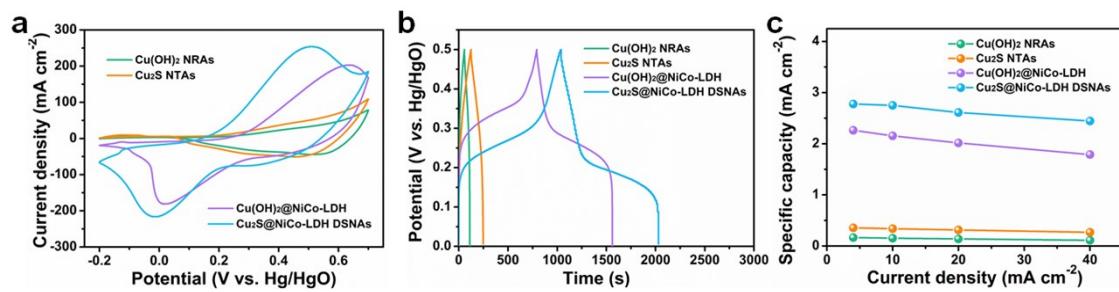


Fig. S14 Electrochemical performances of the $\text{Cu}(\text{OH})_2$ NRAs, Cu_2S NTAs, $\text{Cu}(\text{OH})_2@\text{NiCo-LDH}$ and $\text{Cu}_2\text{S}@\text{NiCo-LDH DSNAs}$. (a) CV curves at 10 mV s^{-1} . (b) GCD curves at 10 mA cm^{-2} . (c) Specific capacities at different current densities.

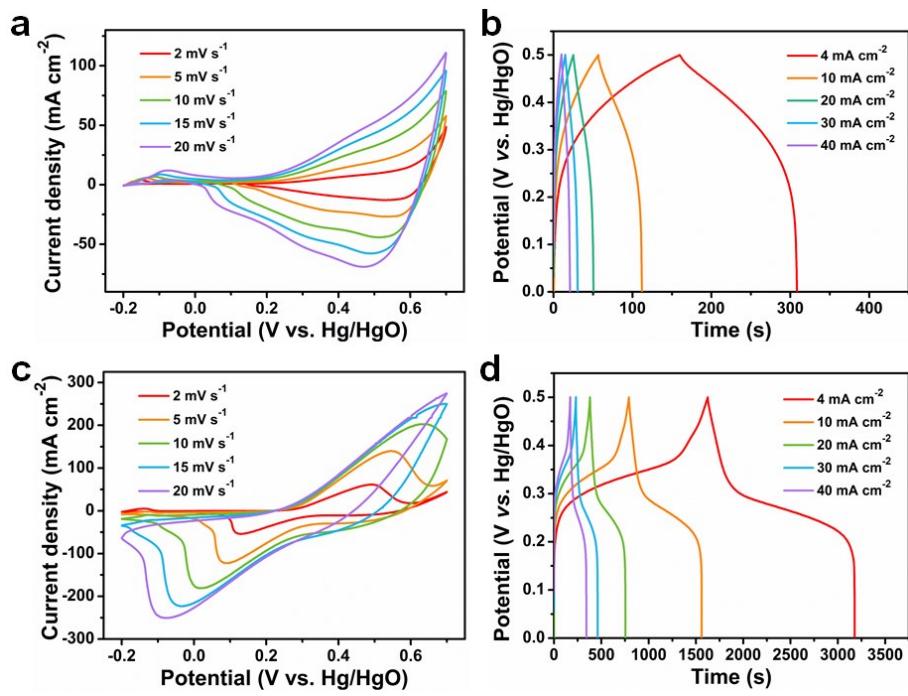


Fig. S15 CV curves of the as-prepared (a) Cu(OH)₂ NRAs, (c) Cu(OH)₂@ NiCo-LDH, at various scan rates, GCD curves of (b) Cu₂S NTAs, (d) Cu₂S@NiCo-LDH DSNA, at various current densities.

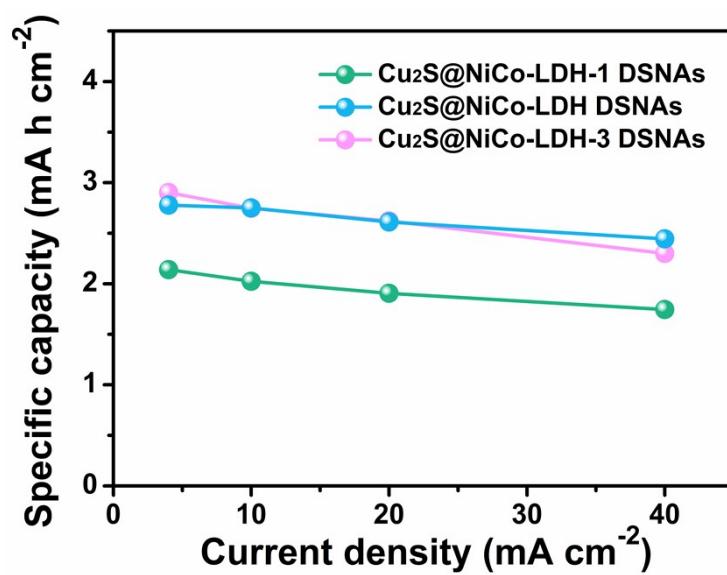


Fig. S16 Specific capacitances of Cu₂S@NiCo-LDH-1 DSNAs, Cu₂S@NiCo-LDH DSNAs and Cu₂S@NiCo-LDH-3 DSNAs at different current densities.

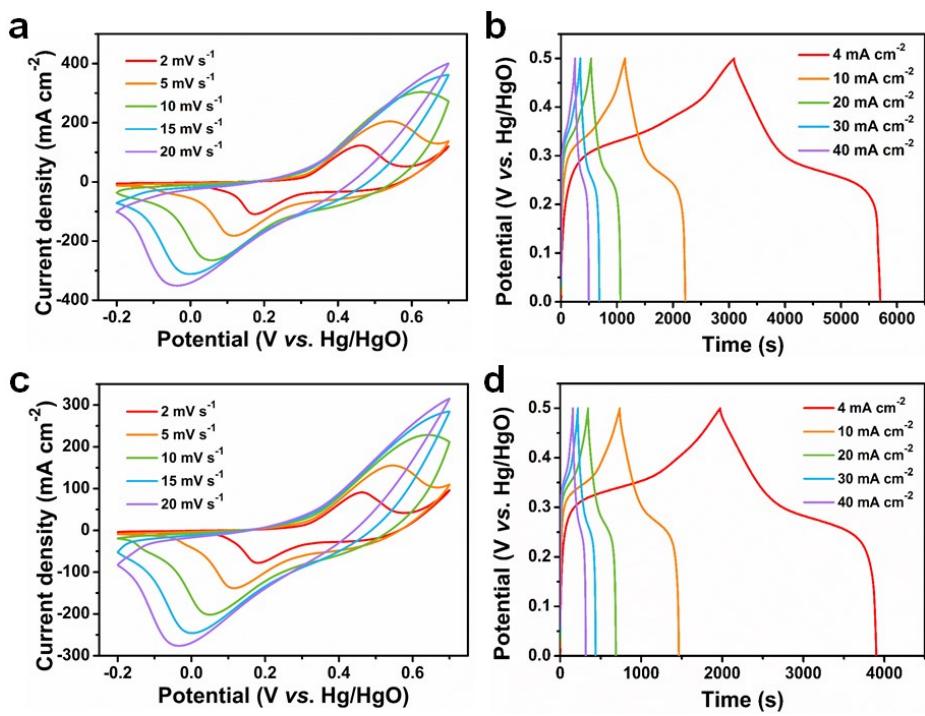


Fig. S17 (a) CV curves and (b) GCD curves of the as-prepared Cu₂S@NiCo-LDH-3 DSNAs, (c) CV curves and (d) GCD curves of the as-prepared Cu₂S@NiCo-LDH-1 DSNAs.

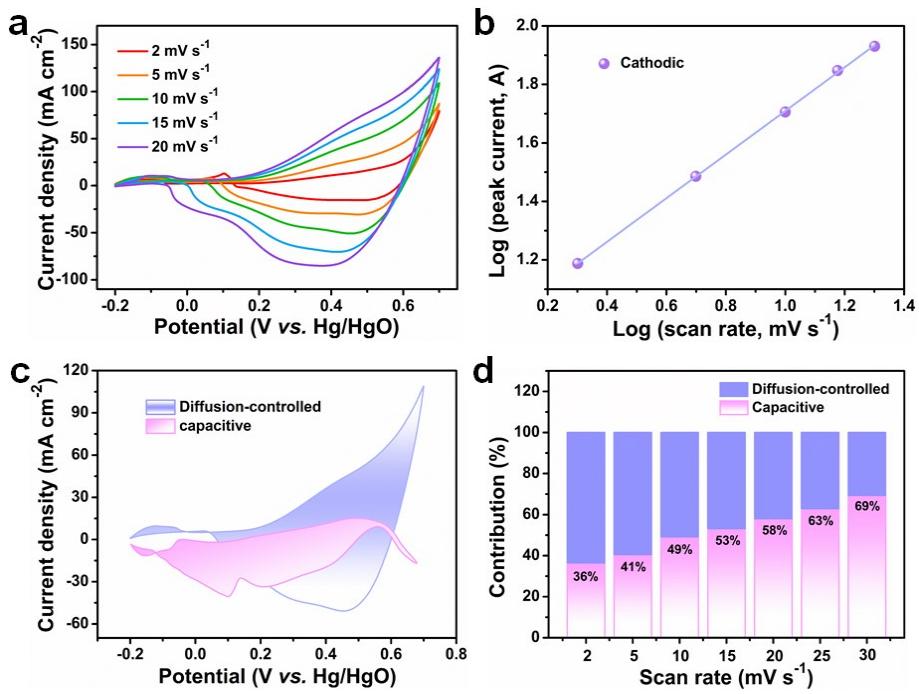


Fig. S18 (a) The CV curves of the Cu_2S NTAs electrode at different scan rates. (b) The plot of $\log(i)$ versus $\log(v)$. (c) Separation of the diffusion and capacitive-controlled currents of the Cu_2S NTAs electrode at a scan rate of 10 mV s^{-1} . (d) Relative contribution of the diffusion and capacitive-controlled charge storage at different scan rates.

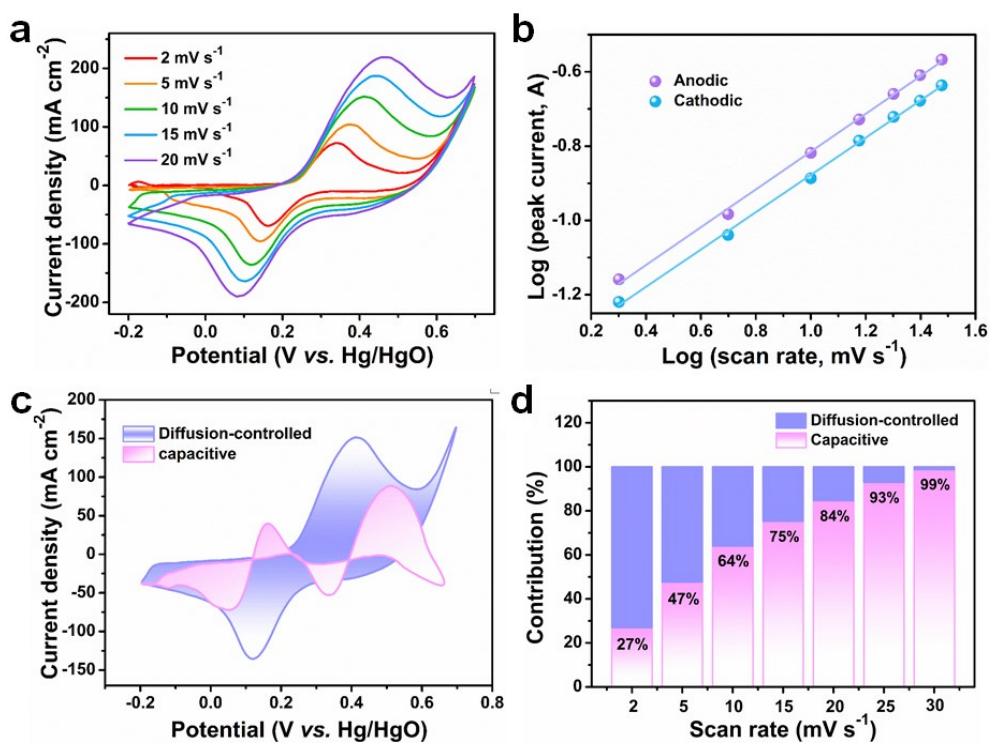


Fig. S19 (a) The CV curves of the NiCo-LDH NSs electrode at different scan rates. (b) The plot of $\log(i)$ versus $\log(v)$. (c) Separation of the diffusion and capacitive-controlled currents of the NiCo-LDH NSs electrode at a scan rate of 10 mV s^{-1} . (d) Relative contribution of the diffusion and capacitive-controlled charge storage at different scan rates.

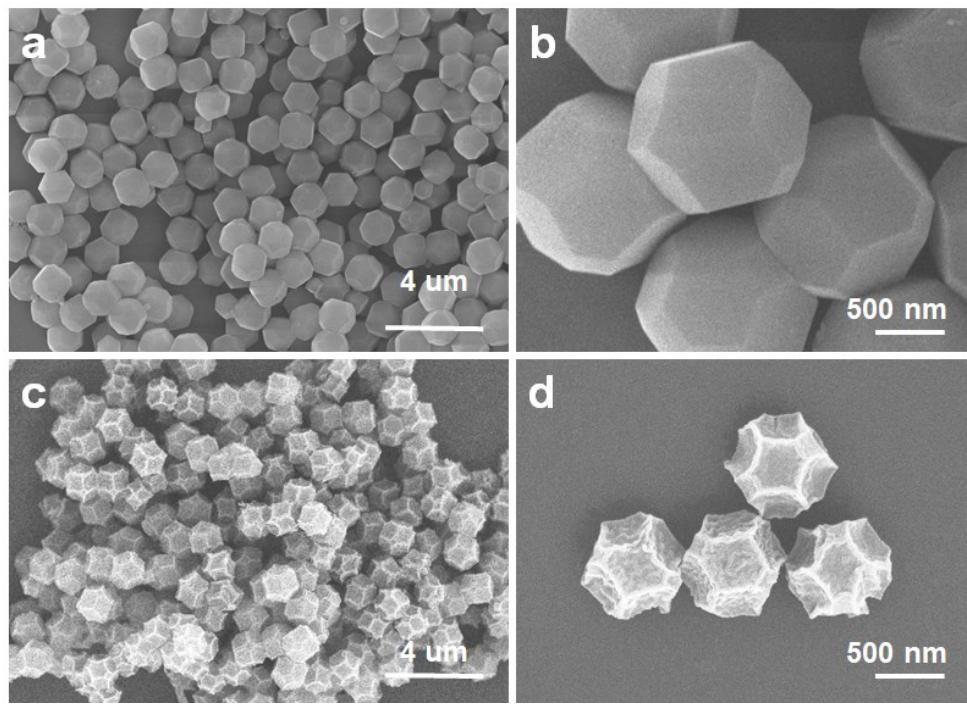


Fig. S20 The FE-SEM images of the as-prepared (a, b) ZIF-8 and (c, d) NPC.

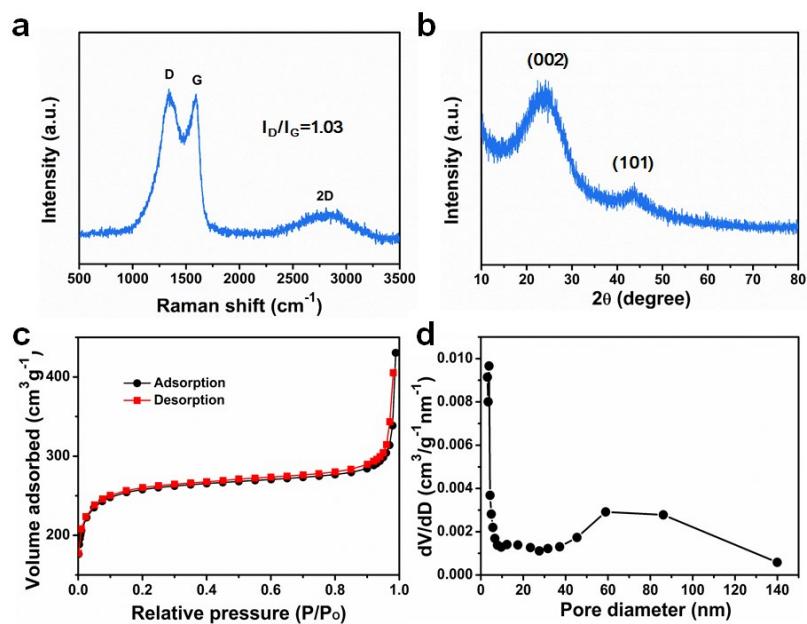


Fig. S21 Structural characterization of the as-prepared NPC: (a) Raman; (b) XRD pattern; (c) N_2 adsorption isotherms and (d) pore size distribution.

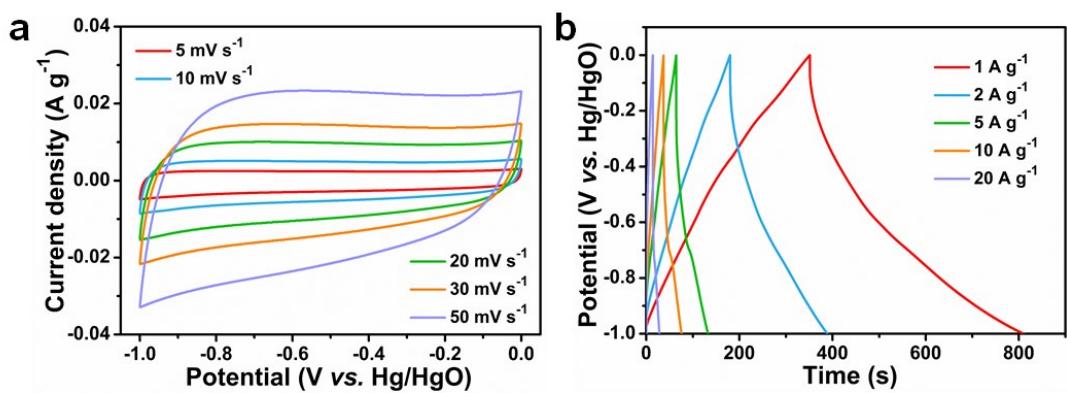


Fig. S22 (a) CV curves and (b) GCD curves of the as-prepared NPC.

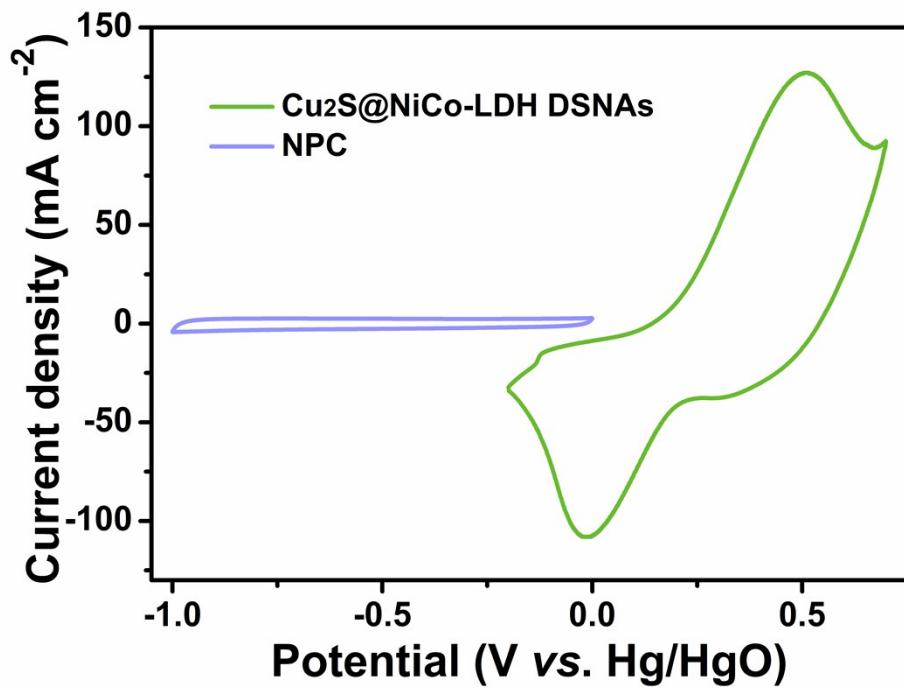


Fig. S23 CV curves of the Cu₂S@NiCo-LDH DSNAs and NPC at 10 mV s⁻¹.

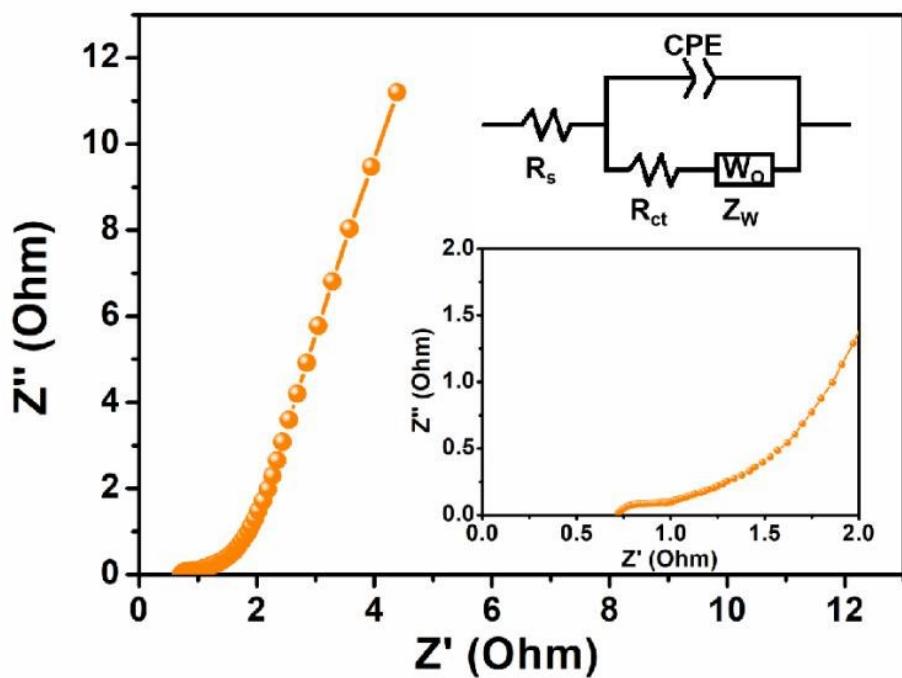


Fig. S24 EIS spectrum of the $\text{Cu}_2\text{S}@\text{NiCo-LDH}$ DSNAs//NPC HSC device with the insets of the EIS spectrum in high-frequency region and the simulated circuit diagram, respectively.

Table S1 Comparative areal capacity values (measured in three-electrode system) of the previously reported transition metal hydroxides-based electrodes with our Cu₂S@NiCo-LDH DSNAs.

Electrode material	Electrolyte	Current density (mA cm ⁻²)	C _a (F cm ⁻²)	Ref.
Cu₂S@NiCo-LDH DSNAs	6 M KOH	4	20.40	This work
Cu ₃ N@CoFe-LDH	2 M KOH	1	3.08	S1
Co(OH) ₂ /HNNF	2 M KOH	5	3.17	S2
Zn–Ni–Co TOH	1 M KOH	3	2.14	S3
CuO@CoFe-LDH NWAs	1 M KOH	2.5	0.87	S4
NC LDH NFAs@NSs/Ni	1 M KOH	2	1.46	S5
ZnCo ₂ O ₄ @Ni _x Co _{2x} (OH) _{6x}	2 M KOH	5	3.35	S6
CoNiO ₂ NWAs@Ni(OH) ₂ NSs/CNTF	3 M KOH	1	6.06	S7

Table S2 Fitting results of the EIS data

Sample	R _s (Ω)	R _{ct} (Ω)	CPE-P (mF)	CPE-T (mF)	W-R (Ω)	W-T (Ω)	W-P (Ω)
Cu ₂ S NTAs	0.80	0.02	0.66	1.05	0.60	0.80	0.49
NiCo-LDH NSs	0.64	0.05	0.67	0.31	1.96	2.79	0.38
Cu ₂ S@NiCo-LDH DSNAs	0.61	0.01	1.18	0.01	0.48	1.30	0.40

Table S3 Comparative areal capacitances, areal energy and power densities of recently reported HSCs with our HSCs.

Electrode material	C _a (F cm ⁻²)	E _a (mW h cm ⁻²)	P _a (mW cm ⁻²)	Ref.
Cu₂S@NiCo-LDH DSNAs	4.2	1.67	4.25	This work
CoMoO ₄ @Co(OH) ₂ /CT//PAC	0.5	0.17	1.50	S8
NC LDH NSs@Ag@CC//AC	0.2	0.08	0.80	S9
NiCo ₂ O ₄ @Co _{0.33} Ni _{0.67} (OH) ₂ //CMK-3-ASC	0.9	0.32	4.00	S10
ZNCO@Ni(OH) ₂ //VN@C	0.6	0.20	2.40	S11
NC LDH NFAs@NSs/Ni//AC@CF	1.2	0.40	2.40	S5
Ni(OH) ₂ -Cu//RGO	2.5	0.95	2.01	S12
NiCo ₂ S ₄ /C	0.5	0.12	0.80	S13
Cu ₃ N@CoFe-LDH//AC	1.2	0.42	1.70	S1

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